Fractal polymeric surfaces by plasma processing

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The aim of this project is to show the use of a low pressure plasma to modify the surfaces morphology of a plastic material, yielding different physical and chemical properties. The surface modification is extremely important for different applications, such as sensor devices, tissue colouring, anti-fouling and antibacterial properties. Recently, nano-structures have been studied exploiting roughness at the micro and nano-scales produced by a competition of plasma etching and deposition processes. Specifically, for PET films an analysis of the distribution function of the rugosity showed they are distributed in space with a fractal index between 2 and 3 [1]. This work is devoted to the plasma treatment of Teflon films. An oxygen capacitive plasma is used in order to promote the chemical etching of samples. We



Figure 1: Image of the used plasma device.

analyse the plasma treated samples by means of SEM microscopy and by evaluating the contact and roll-off angles. Different statistical tools are employed in order to study the morphological descriptors as a function of the main plasma parameters, such as power, treatment time and vacuum pressure. Finally microbiological analyses are performed in order to evaluate the fouling and anti-fouling properties of the samples.

References

[1] C. Piferi et al., Advanced Materials Interfaces 8, 19 (2021)